

**LIST OF PRIOR ART  
CITED BY APPLICANT***(Use several sheets if necessary)***Atty. Docket No. (Optional)**

17160

**Application Number**

10/697,755

**Applicant(s)**

Hideaki Nobusawa et al.

**Filing Date**

October 30, 2003

**Group Art Unit**

2683

**U.S. PATENT DOCUMENTS**

| EXAMINER<br>INITIAL* |    | DOCUMENT NUMBER | DATE    | NAME      | CLASS | SUBCLASS | FILING DATE<br>(if appropriate) |
|----------------------|----|-----------------|---------|-----------|-------|----------|---------------------------------|
|                      | AA | US6,307,541 B1  | 10/2001 | Ho et al. |       |          |                                 |
|                      | AB |                 |         |           |       |          |                                 |

**FOREIGN PATENT DOCUMENTS**

|  | REF | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | TRANSLATION |    |
|--|-----|-----------------|------|---------|-------|----------|-------------|----|
|  |     |                 |      |         |       |          | YES         | NO |
|  |     |                 |      |         |       |          |             |    |
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|  |     |                 |      |         |       |          |             |    |
|  |     |                 |      |         |       |          |             |    |

**OTHER DOCUMENTS** *(Including Author, Title, Date, Pertinent Pages, Etc.)*

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**EXAMINER****DATE CONSIDERED**

\* EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.